



**Our Low-K solutions give you
a quicker ride to the next node.**

As soon as you reach one technology node, the next one will be waiting right around the corner. And we will be, too.

Our comprehensive mix of Low-K dielectrics includes the Dow Corning¹ Z3MS^{TM1}, Z4MS^{TM2}, ZTOMCATS^{TM2} and Z2DM^{TM1} precursors, the Schumacher OMCATS and the highly extendible DEMSTM and MesoELKTM precursors. And our long-standing OEM relationships and global support make your ramp-up fast and efficient, no matter where you are.

Wherever the roadmap leads, we'll get you there. For more information, call 800-654-4567 or visit our Web site.

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PRODUCTS 

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